

AMENDMENT TO THE SPECIFICATION

Please amend the specification as follows:

Please insert the following at page 1, between lines 1 and 2:

CROSS-REFERENCE TO RELATED APPLICATIONS

This application is a National Phase Application (35 U.S.C. § 371) of PCT/JP2003/014780 and claims priority of Japanese Application No. 2002-336738, filed November 20, 2002, and of Japanese Application No. 2002-336739, filed November 20, 2002.

Please substitute the following marked-up paragraph for that at page 6, lines 7-18:

Optical characteristics of the fingerprint easily erasable film of the present invention may differ depending on the use, and they are not particularly limited. However, it preferably has high transparency as the whole film. Specifically, it preferably shows 82% or more of total light transmittance defined in JIS-K 7105:1981. Further, the film preferably shows a haze of 35.0% or less, more preferably 10% or less, further preferably 5.0% or less. The lower limit of the haze is preferably 1.5% or more. By making the haze fall within the range of 1.5 to 35.0%, ingredients of fingerprint remaining after wiping can be made visible while maintaining transparency.

Please substitute the following marked-up paragraph for that at page 7, lines 13-20:

When the fingerprint easily erasable film of the present invention consists of a substrate alone as shown in Fig. [[1]] 3, i.e., when the matted surface is formed as the

Reply to Office Action of March 25, 2008
Application No.: 10/535,242
Examiner: A. A. CHEVALIER
Art Unit: 1794

surface of the substrate, a material showing high wet tension is preferred as the material constituting the substrate. Examples of the substrate showing high wet tension include polyester films, acrylic resin films and so forth.